Monday Afternoon, November 4, 2024

Nanoscale Science and Technology Room 114 - Session NS1+2D+QS-MoA

Functionality in 2D Nanostructures and Devices

Moderators: Nikolai Klimov, NIST, Andy Mannix, Stanford University

1:30pm NS1+2D+QS-MoA-1 Low-Dimensional Neuromorphic Electronic Materials and Applications, Mark Hersam, Northwestern University INVITED

The exponentially improving performance of digital computers has recently slowed due to the speed and power consumption issues resulting from the von Neumann bottleneck. In contrast, neuromorphic computing aims to circumvent these limitations by spatially co-locating logic and memory in a manner analogous to biological neuronal networks [1]. Beyond reducing power consumption, neuromorphic devices provide efficient architectures for image recognition, machine learning, and artificial intelligence [2]. This talk will explore how low-dimensional nanoelectronic materials enable gate-tunable neuromorphic devices [3]. For example, by utilizing selfaligned, atomically thin heterojunctions, dual-gated Gaussian transistors have been realized, which show tunable anti-ambipolarity for artificial neurons, competitive learning, spiking circuits, and mixed-kernel support vector machines [4,5]. In addition, field-driven defect motion in polycrystalline monolayer MoS₂ enables gate-tunable memristive phenomena that serve as the basis of hybrid memristor/transistor devices (i.e., 'memtransistors') that concurrently provide logic and data storage functions [6]. The planar geometry of memtransistors further allows multiple contacts and dual gating that mimic the behavior of biological systems such as heterosynaptic responses [7]. Moreover, control over polycrystalline grain structure enhances the tunability of potentiation and depression, which enables unsupervised continuous learning in spiking neural networks [8]. Finally, the moiré potential in asymmetric twisted bilayer graphene/hexagonal boron nitride heterostructures gives rise to robust electronic ratchet states. The resulting hysteretic, non-volatile injection of charge carriers enables room-temperature operation of moiré synaptic transistors with diverse bio-realistic neuromorphic functionalities and efficient compute-in-memory designs for low-power artificial intelligence and machine learning hardware [9].

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[3] M. E. Beck, et al., ACS Nano, 14, 6498 (2020).

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[6] X. Yan, et al., Advanced Materials, 34, 2108025 (2022).

[7] H.-S. Lee, et al., Advanced Functional Materials, 30, 2003683 (2020).

[8] J. Yuan, et al., Nano Letters, 21, 6432 (2021).

[9] X. Yan, et al., Nature, 624, 551 (2023).

2:00pm NS1+2D+QS-MoA-3 Defect Manipulation in van der Waals Heterostructures and its Applications, Son Le, Laboratory for Physical Sciences; T. Mai, M. Munoz, A. Hight Walker, C. Richter, 100 Bureau Dr.; A. Hanbicki, A. Friedman, 8050 Greenmead Dr. INVITED Reliable and accurate spatial doping of 2-dimensional (2D) materials is important for future applications using this novel class of materials. Here, we present our work on photo-doping of an h-BN/Graphene/h-BN heterostructure. Natural defect states in bulk h-BN can remotely dope graphene and can be optically activated or deactivated. In this way, we can modify both the carrier density and type in graphene accurately and reversibly by several orders of magnitude. Using a spatially-resolved light source, we can activate photo-dopants in selected areas of the sample, and by laterally modulating the doping, we have created PNP junction (PNPJ) devices. In-situ quantum Hall measurements were used to demonstrate the effectiveness of this doping technique and characterize the electrostatic profile of the PNPJ. Doping and undoping the heterostructure in a specific sequence, we were able to introduce and destroy correlation among the dopants. Defect correlation greatly enhances carrier mobility while the destruction of this correlated state significantly degrades the carrier mobility in the graphene, effectively creating a mobility switch. An elegant demonstration of this mobility switch is the observation of spin and valleyresolved Landau levels of the graphene in the quantum Hall regime with high-mobility, dopant correlated states, and spin and valley -degenerate Landau levels in the low-mobility, dopant uncorrelated states. I will discuss

ongoing studies to better understanding the nature of these defects with photo-doping measurements of different hBN thicknesses as well as hBN from different sources. This doping technique opens up the possibility to engineer novel device and expand the applications of 2D heterostructures.

2:30pm NS1+2D+QS-MoA-5 Extraordinary Tunnel Electroresistance in Layer-by-Layer Engineered Van Der Waals Ferroelectric Tunnel Junctions, *Qinqin Wang*, Department of Electrical and Computer Engineering and Quantum Technology Center, University of Maryland, College Park

The ability to engineer potential profiles of multilayered materials is critical for designing high-performance tunneling devices such as ferroelectric tunnel junctions (FTJs). FTJs comprise asymmetric electrodes and a ferroelectric spacer, promising semiconductor platform-compatible logic and memory devices. However, the traditional FTJs consisting of metal/oxide/metal multilayer heterostructures can only exhibit modest tunneling electroresistance (TER, usually <106), which is fundamentally undermined by the unavoidable defect states and interfacial trap states. Here, we constructed van der Waals (vdW) FTJs by a layered ferroelectric CuInP₂S₆ (CIPS) and graphene. Owing to the gigantic ferroelectric modulation of the chemical potentials in graphene by as large as ~1 eV, we demonstrated a giant TER of 109. While inserting just a monolayer MoS2 between CIPS/graphene, the off state is further suppressed, leading to >10¹⁰ TER. Our discovery opens a new solid-state paradigm where potential profiles can be unprecedentedly engineered in a layer-by-layer fashion, fundamentally strengthening the ability to manipulate electrons' tunneling behaviors and design advanced tunneling devices.

Keywords: 2d materials, ferroelectric tunnel junctions, tunneling electroresistance

2:45pm NS1+2D+QS-MoA-6 Scanning Tunneling Microscopy Studies of Twisted Transition Metal Dichalcogenides , Adina Luican-Mayer, STEM 150 Louis Pasteur Private, Canada

Material systems, devices, and circuits, based on the manipulation of individual charges, spins, and photons in solid-state platforms are key for quantum technologies. Two-dimensional (2D) materials present an emerging opportunity for the development of novel quantum technologies, while also pushing the boundaries of fundamental understanding of materials. Our laboratory aims to create quantum functionality in 2D systems by combining fabrication and assembly techniques of 2D layers with atomically precise microscopy.

In this talk, I will focus on experimental observations of novel phenomena in moiré structures created by twisting 2D layers using scanning tunnelling microscopy and spectroscopy. I will discuss the demonstration of reversible local response of domain wall networks using scanning tunneling microscopy in ferroelectric interfaces of marginally twisted WS₂ bilayers. Moreover, in the case of twisted WS₂ bilayers close to 60°, we observe signatures of flat bands and study the influence of atomic relaxation on their band structure.

Author Index

Bold page numbers indicate presenter

— F —

Friedman, Adam: NS1+2D+QS-MoA-3, 1 — H —

Hanbicki, Aubrey: NS1+2D+QS-MoA-3, 1 Hersam, Mark: NS1+2D+QS-MoA-1, 1 Hight Walker, Angela: NS1+2D+QS-MoA-3, 1 — L — Le, Son: NS1+2D+QS-MoA-3, 1 Luican-Mayer, Adina: NS1+2D+QS-MoA-6, 1 — M —

Mai, Thuc: NS1+2D+QS-MoA-3, 1 Munoz, Maria: NS1+2D+QS-MoA-3, 1 — R — Richter, Curt: NS1+2D+QS-MoA-3, 1 — W — Wang, Qinqin: NS1+2D+QS-MoA-5, 1